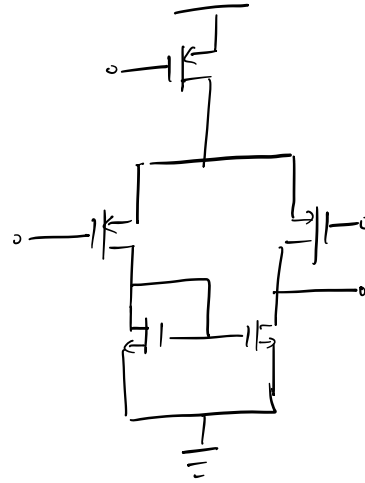
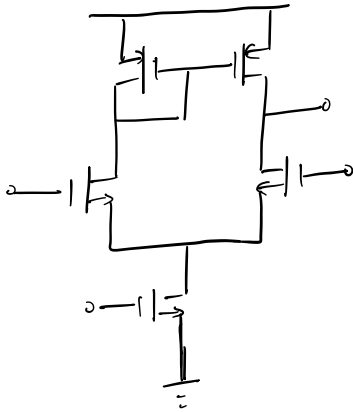
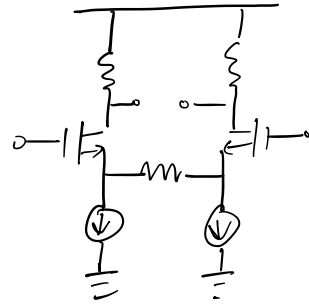
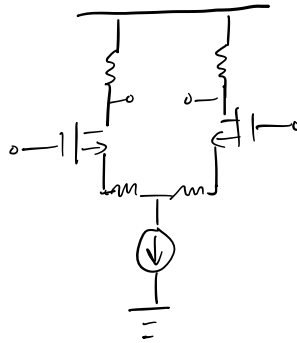
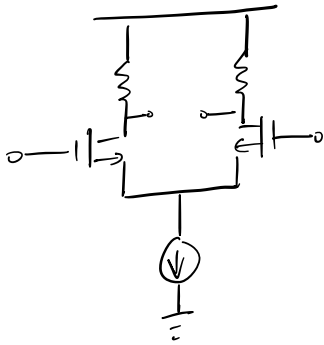
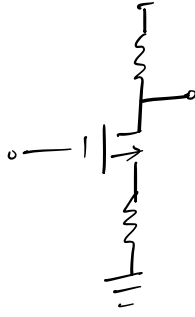
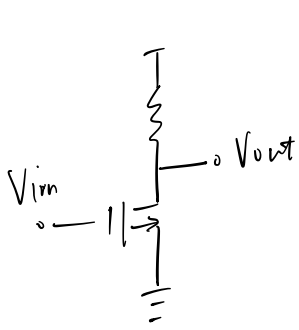


D

定性: $V_{out} - V_{in}$ 趋势

定量 $\left\{ \begin{array}{l} \text{大信号} \longrightarrow A_v, SW(\text{输入, 输出摆幅}) \\ \text{小信号} \longrightarrow A_v, R_{in}, R_{out} \end{array} \right.$

CS

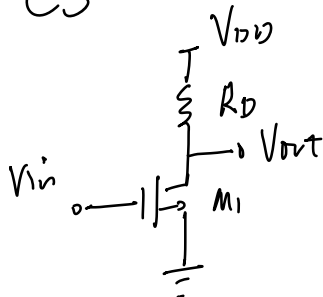
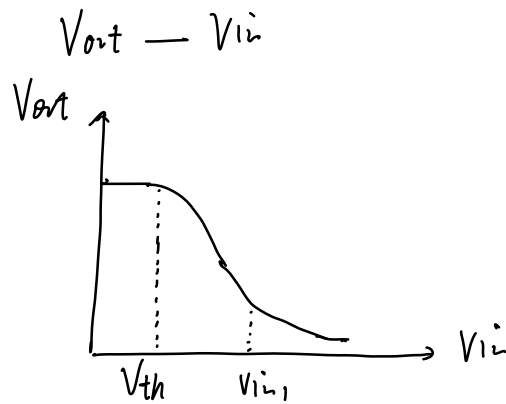


图 1



$$A_v = g_m R_D$$

CS (R_s)

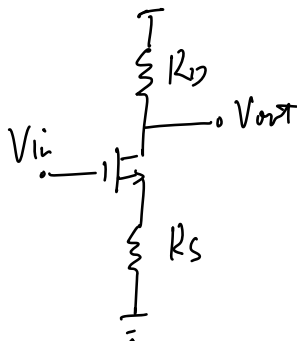


图 2

$$A_v = \frac{R_D}{R_s + \frac{1}{g_m}}$$

① 使输入器件更线性

② 增大 R_{out}

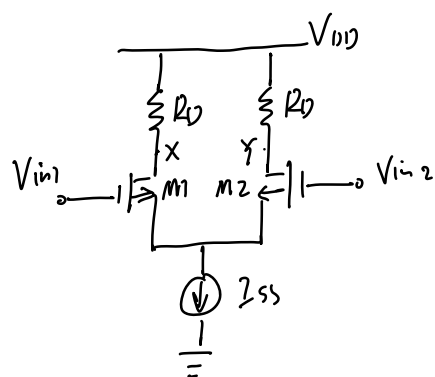


图 3

相比起单边放大, 能抑制共模噪声。

共模信号通常为电路偏置, 比差模信号要大。

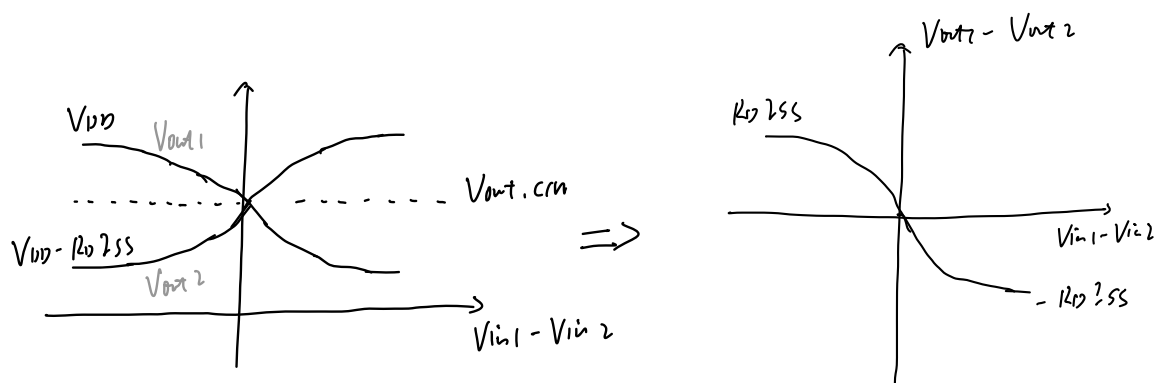
(1) 定性分析

$$V_{out} \sim V_{in} (-\infty \rightarrow +\infty)$$

差模

$$V_{in1} \ll V_{in2}$$

- $V_{in1} = 0$, $V_{in2} = V_{DD}$, M_1 off, M_2 triode,
 M_2 相当于一个小电阻 (R_{on})
 $I_{D1} = 0$, $I_{D2} = I_{SS}$, $V_X = V_{DD}$, $V_Y = V_{DD} - I_{SS} R_D$
- V_{in1} 增大, V_{in2} 减小
 V_{in1} 接近 V_{thn} 时, M_1 逐渐导通并进入 sat.
 R_D 有电流流过, $V_X = V_{DD} - I_{D1} R_D$
 因随着 $V_{in1} \uparrow$, $I_{D1} \uparrow$, $V_X \downarrow$
 $V_{in2} \downarrow$, $I_{D2} \downarrow$, $V_Y \uparrow$
- 当 $V_{in1} = V_{in2}$, $I_{D1} = I_{D2}$, $V_X = V_Y$
- V_{in1} 继续 $\uparrow$, V_{in2} 继续 $\downarrow$
 $I_{D1} \uparrow$, $V_X \downarrow$; $I_{D2} \downarrow$, $V_Y \uparrow$
- $V_{in1} = V_{DD}$, $V_{in2} = 0$
 $V_X = V_{DD} - I_{SS} R_D$, $V_Y = V_{DD}$



共模

按单端输出看, 和CS一样.

定量分析

大信号

差模:

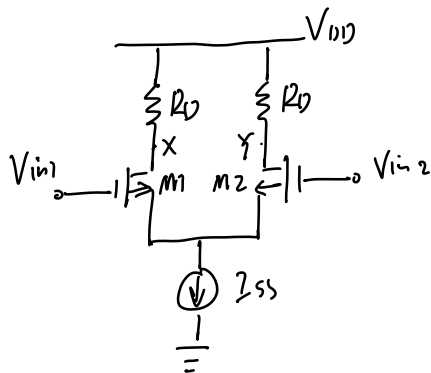


图 3

$$A_v = G_m R_{out}$$

$$G_m = \frac{\partial I_D}{\partial V_{in}}$$

$$V_{in2} - V_{in1} = V_{as1} - V_{as2}$$

$$V_{as} = \sqrt{\frac{2 I_D}{\mu_n C_{ox} \frac{W}{L}}} + V_{th}$$

$$V_{in2} - V_{in1} = \sqrt{\frac{2 I_{D2}}{\mu_n C_{ox} \frac{W}{L}}} - \sqrt{\frac{2 I_{D1}}{\mu_n C_{ox} \frac{W}{L}}}$$

$$\frac{\partial I_D}{\partial \Delta V_{in}} = \frac{\frac{1}{2} \mu_n C_{ox} \frac{W}{L} \frac{-s}{\mu_n C_{ox} \frac{W}{L}} \Delta V_{in}}{\sqrt{\frac{4 I_{SS}}{\mu_n C_{ox} \frac{W}{L}} - \Delta V_{in}^2}}$$

$$\text{当 } \Delta V_{in} = 0, |A_v| = \sqrt{\mu_n C_{ox} \frac{W}{L} I_{SS}} R_D$$

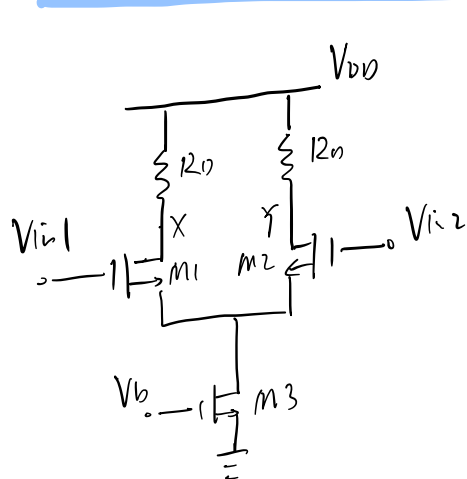
共模:

$$\text{单支路输出: } V_{out} = V_{DD} - I_D R_D$$

$$I_D = \frac{1}{2} I_{SS}$$

摆幅 (SW)

输入摆幅 (共模)
 输出摆幅 (差模)



$V_{in,cm}$ SW

$$V_{DS2} + V_{DS3} - V_{th3} \leq V_{in,cm} \leq \min[V_{DD}, V_{DD} - \frac{I_{SS}}{2} R_D + V_{th}]$$

当 MOS 在饱和区边缘

$$V_{DD} - I_D R_D = V_{in} - V_{th}$$

$$I_D = \frac{I_{SS}}{2}$$

$$V_{in} = V_{DD} - \frac{I_{SS}}{2} R_D + V_{th}$$

$V_{out,dm}$ SW

$$V_{out,dm,max} = V_{DD}$$

M_1, M_2 饱和区边缘: $V_x = V_{in} - V_{th}$
 或 $V_y = V_{in} - V_{th}$

$$V_{in} = V_{in,cm} + V_{in,dm}$$

$$V_{in,cm} \gg V_{in,dm}$$

$$\text{故 } V_x (V_y) \geq V_{in,cm} - V_{th}$$

故输出摆幅有下限

$$V_{in,cm} - V_{th} \leq V_{out,dm} \leq V_{DD}$$

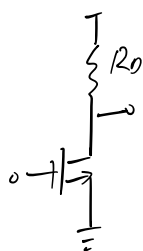
小信号

A_v { 叠加法 (电路不对称时亦可用)
半边电路法 (完全对称时可用)

$$A_v = \frac{V_f - V_o}{V_{in2} - V_{in1}} = -g_m R_D$$

R_{in} . R_{out} 没研究过

进阶

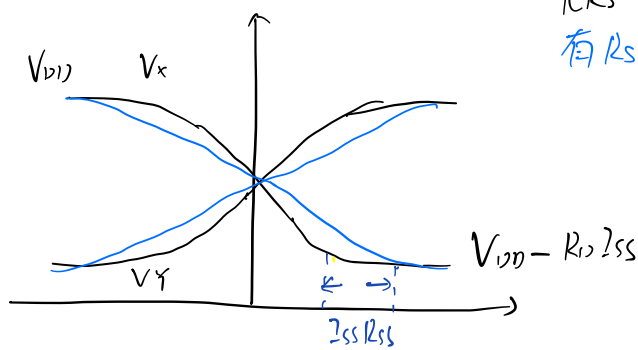
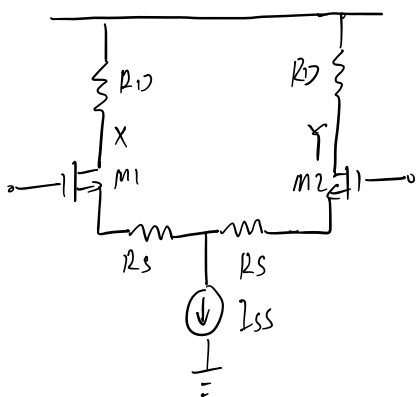


$$A_v = -g_m R_D$$



$$A_v = -\frac{R_D}{R_S + \frac{1}{g_m}}$$

↓
更接近平数
更线性



无 R_S
有 R_S

更线性

$$A_{v, dm} = -\frac{R_D}{\frac{1}{g_m} + R_S} \quad (A_v \downarrow)$$

SW

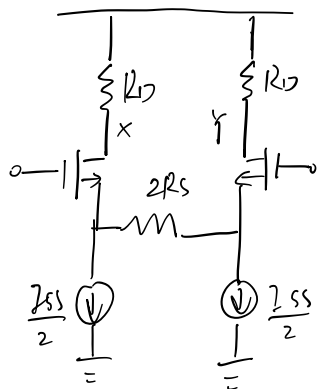
输入 $\pm R_S I_{SS}$
输入摆幅 $\uparrow$

输出 SW

$$V_{in, cm} - V_{th} \leq V_{out} \leq V_{DD}$$

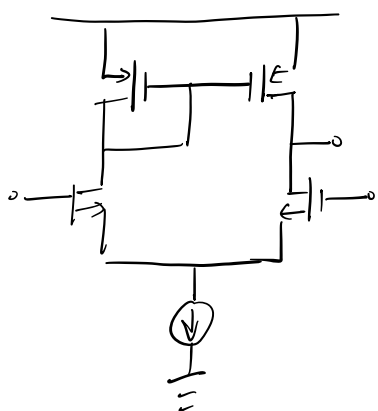
$$V_{in, cm} > \frac{R_S I_{SS}}{2}$$

故输出摆幅减小 $R_S I_{SS}$



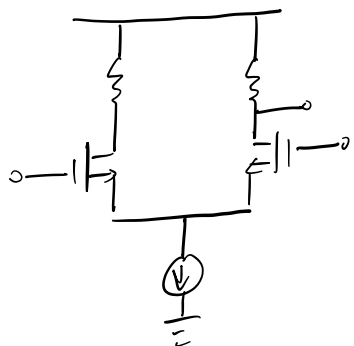
对共模信号, $2R_s$ 上无电流.
故 输出摆幅不会被减小.

五管 OTA



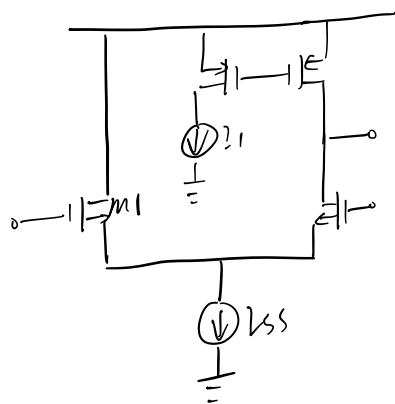
差分对 双端输入 $\rightarrow$ 单端输出.

① 全差分取单边



增益减半, SW 减半, 有反馈噪声

②

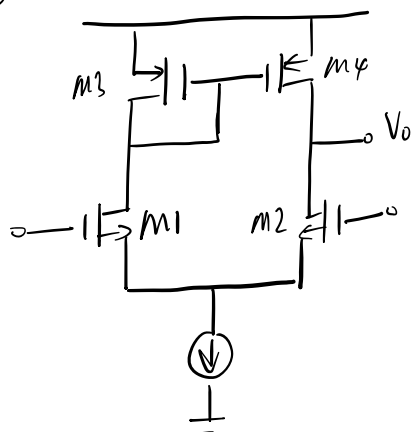


I_{D1} 被浪费 3.

大信号

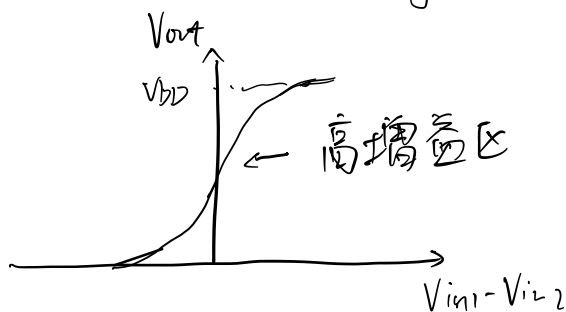
差模:

②



增益 (小信号)

$$|A_v| = g_{m1} (r_{o1} || r_{o4}) \frac{2g_{m4} r_{o4} + 1}{2(g_{m4} r_{o4} + 1)}$$



电流镜偏置与输入相关。

Output SW: $\underline{V_{in,cm} - V_{th}} \leq V_{out} \leq V_{DD}$

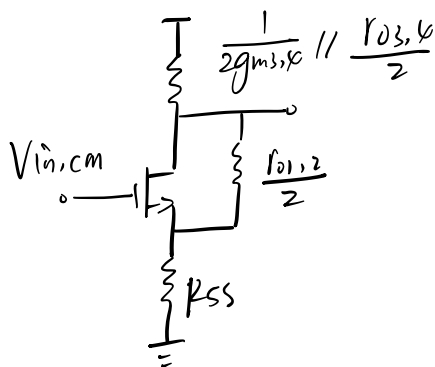
$V_{in,cm}$ 影响输出摆幅

input SW: $V_{GS1,2} + V_{DS5,min} \leq V_{in,cm} \leq V_{DD} - V_{thp}$

推挽加快电路瞬态。

将差动输入转换成大摆幅的单端输出。

共模:



$$A_{cm} = \frac{-\frac{1}{2g_{m3,p}} \parallel \frac{r_{o3,p}}{2}}{\frac{1}{2g_{m1,2}} + R_{SS}}$$

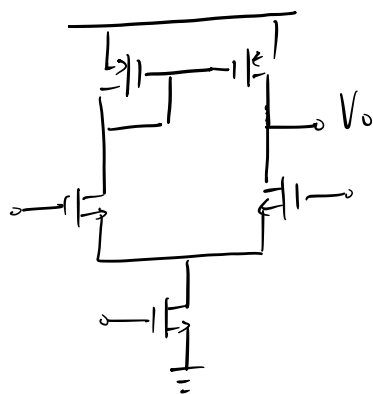
$$CMRR = \left| \frac{A_{dm}}{A_{cm}} \right|$$

$$= (1 + 2g_{m1,2}R_{SS})g_{m3,p}(r_{o1,2} \parallel r_{o3,p})$$

会有共模噪声.

有限的 CMRR

一般需要共模反馈不使用.

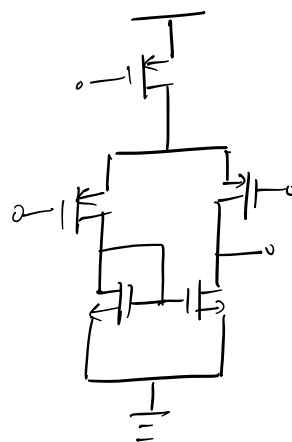


Nmos OTA 有下限

Pmos OTA 有上限

选择时看输入信

号偏高或是偏低.



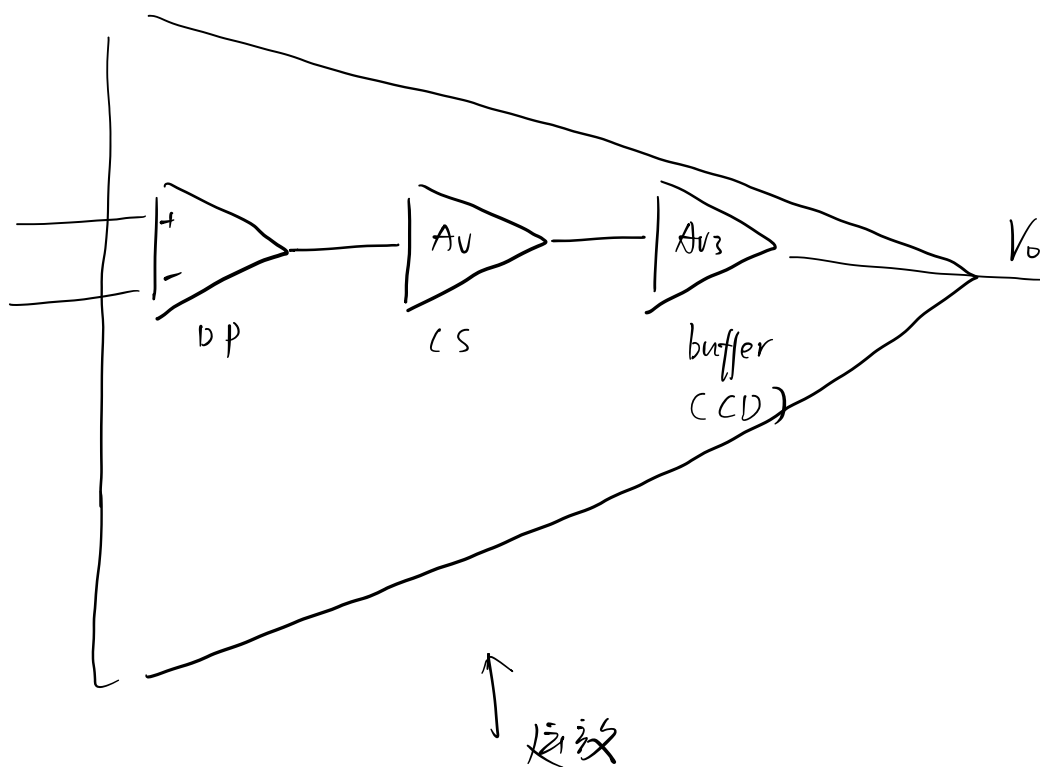
如果二者都引入.

通常 nmos 电子迁移率比 pmos 快, 同样速率下, pmos

尺寸比 nmos 大 2~3 倍.

但 pmos 噪声小, 更容易匹配 (差分对称)

电源越来越低, 用 pmos 也越来越多.



差分对通常作输入级。